

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

STRUCTURE AND METHOD FOR LOCAL RESISTOR
ELEMENT IN INTEGRATED CIRCUIT TECHNOLOGY

Application Number : 10/708023

Confirmation Number:

First Named Applicant: Jason Gill

Attorney Docket Number: BUR920030118US1

Art Unit: 2826

Examiner: Kevin Quinto

Search string: (5232865 or 5330930 or 5665629 or 5930638 or 6117792 or 20030116820 or 20020003311),pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
✓	1	5232865	1993-08-03	Manning et al.			
✓	2	5330930	1994-07-19	Chi			
✓	3	5665629	1997-09-09	Chen et al.			
✓	4	5930638	1999-07-27	Reedy et al.			
✓	5	6117792	2000-09-12	Kitagawa			

US Published Applications

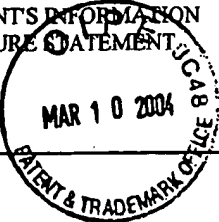
Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
✓	1	20030116820	2003-06-26	Daubenspeck et al.			
✓	2	20020003311	2002-01-10	Uematsu			

Signature

Examiner Name	Date
Kevin Quinto	9/3/07

Subst. Form PTO-1449
 APPLICANT'S INFORMATION
 DISCLOSURE STATEMENT



Atty. Docket No.: BUR920030118US1 (IBU-10-5799)

Serial No.:

16/1588023

Applicant: Gill et al

Filing Date: Herewith 02/03/04

Group: 2826

U.S. PATENT DOCUMENTS

Initial*		Document No.	Date	Name	Class	Subcl.	Filing Date
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						

FOREIGN PATENT DOCUMENTS

		Document No.	Date	Country	Class	Subcl.	Translation?
<i>12</i>	AJ	JP4151825A	05/25/1992	Japan	H01L	21/28	Abstract only
	AK						
	AL						
	AM						

OTHER DOCUMENTS

<i>12</i>	AN	"VERTICALLY INTEGRATED LOAD RESISTOR FOR MOS STATIC RAM CELLS", IBM Technical Disclosure Bulletin, Vol. 26, No. 10B, March 1984, pgs. 5675-5677					
	AO						
	AP						
	AQ						
	AR						

Examiner:

Kevin Quimb

Date Considered:

9/3/04

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if in conformance and not considered.

Include copy of this form with next communication to applicant.